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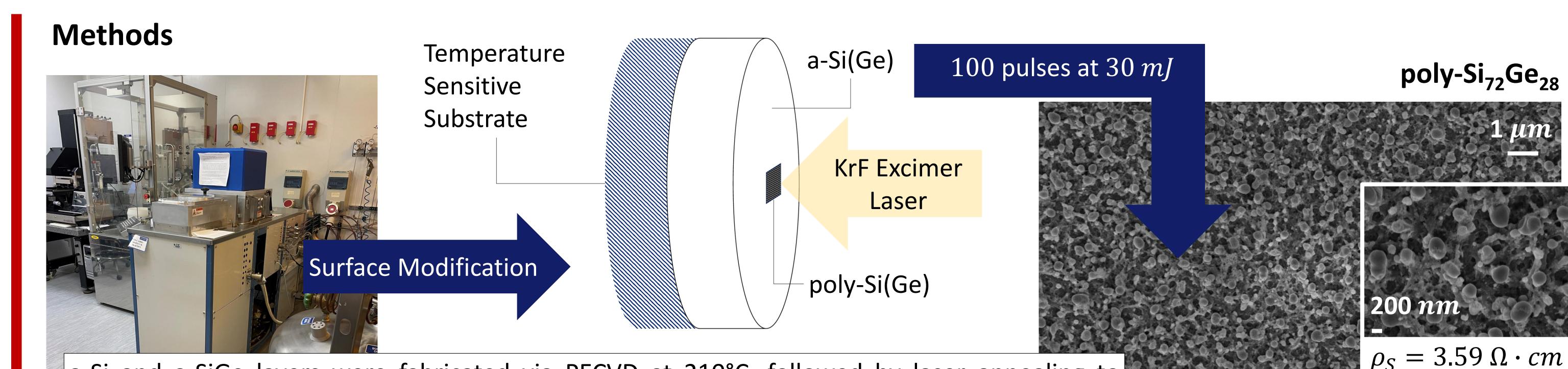


Introduction

Nanostructured Poly-Si and Poly-SiGe Layers for **Enhanced Energy Harvesting Applications** Joumana El-Rifai^{1,2,*}, Eliane Bsaibess^{1,2}, Stavros Christopoulos^{1,2}, Fabien Giovannelli³, Ahmed Slimani^{1, 2}, Valerie Laux-Le Guyon^{1, 2}

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Energy harvesting focuses on capturing small amounts of energy from ambient sources, such as light, heat, and vibrations, to power lowenergy devices. In this work we present a waste-free, low thermal budget fabrication method for nanostructured polycrystalline silicon (poly-Si) and silicon-germanium (poly-SiGe) layers. These nanostructured layers significantly improve optical absorption and, in the case of poly-SiGe, enhance thermoelectric performance, making them ideal for hybrid energy harvesting applications on temperature-sensitive substrates where efficient, low-cost, and high-output devices are needed.



a-Si and a-SiGe layers were fabricated via PECVD at 210°C, followed by laser annealing to induce nanostructuring and transform them into polycrystalline form. This low thermal budget process preserves substrate integrity, making it suitable for temperature-sensitive applications.

Results

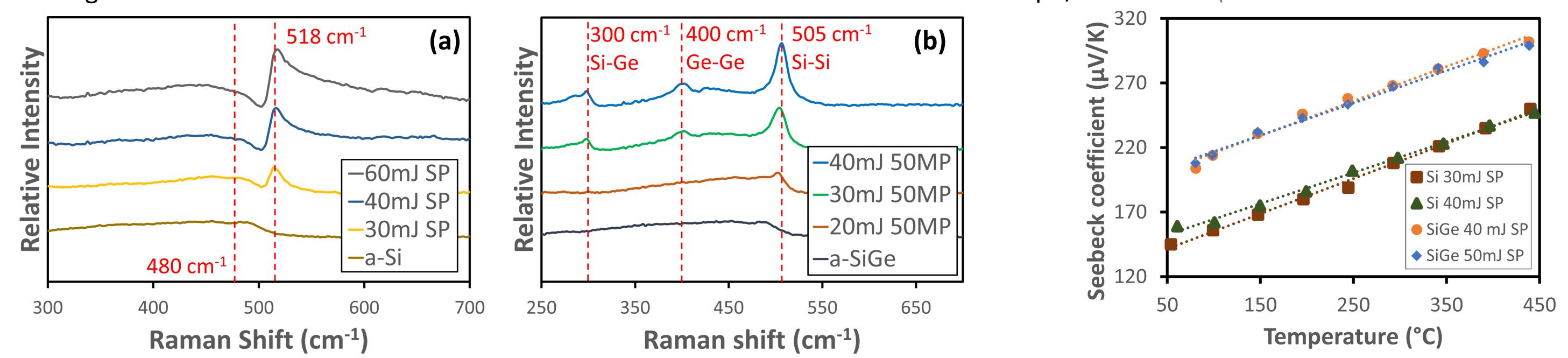
<u>Raman spectra</u> of (a) a-Si and (b) a-SiGe layers, and polycrystalline layers annealed with (a) single (SP) and (b) multiple pulses (MP) at varying energies.

Seebeck coefficient in nanostructured Si and Si₇₂Ge₂₈ layers exceeds conventional methods, which peak at 160 μV/K at 900°C.¹ (Measurements use ULVAC ZEM-3)

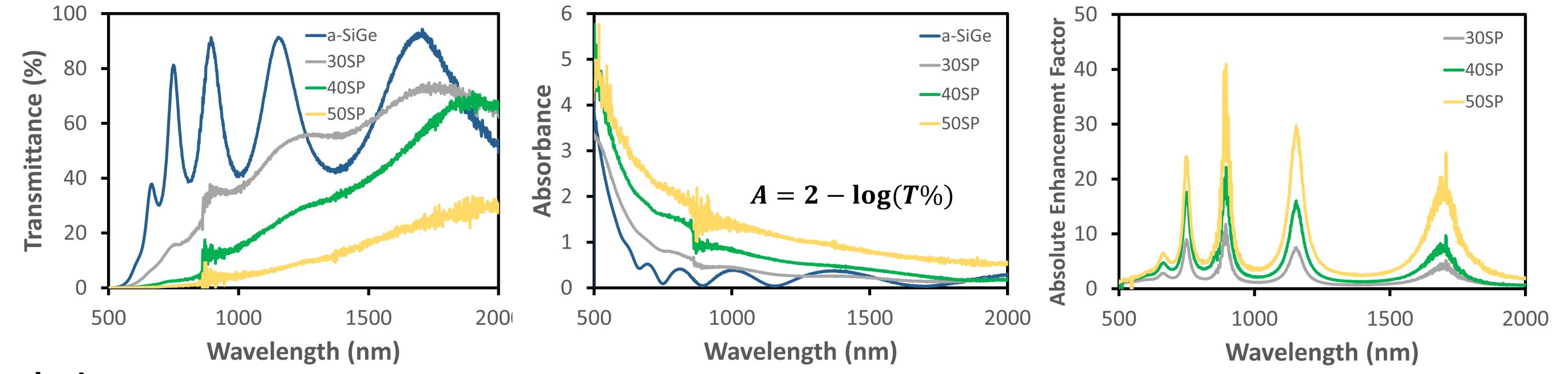
poly-Si₇₂Ge₂₈

 $R_a = 494.7 \ nm$

 $R_a = 528.8 \, nm$



Optical spectra reveal that increasing laser energy reduces transmission at longer wavelengths, due to higher absorption by crystalline Si(Ge) compared to its amorphous form. ^{2,3} (Spectra are collected using the UV-Vis-IR Perkin Elmer Lambda 1050+)



Conclusions

Surface nanostructuring of a-Si and a-Si₇₂Ge₂₈ with a KrF excimer laser enhances optical absorption and thermoelectric properties. Adjusting laser parameters produced polycrystalline layers, with poly-Si₇₂Ge₂₈ showing a 43-fold increase in absorption at 880 nm and a Seebeck coefficient rise from 215 $\mu V/K$ at 100°C to 300 $\mu V/K$ at 450°C, indicating potential for hybrid energy harvesting.

References:

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